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Skinner et al.

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(54) **MAGNETIC CONTACTS**

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See application file for complete search history.

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H01L 25/065 (2006.01)
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H01L 23/00 (2006.01)

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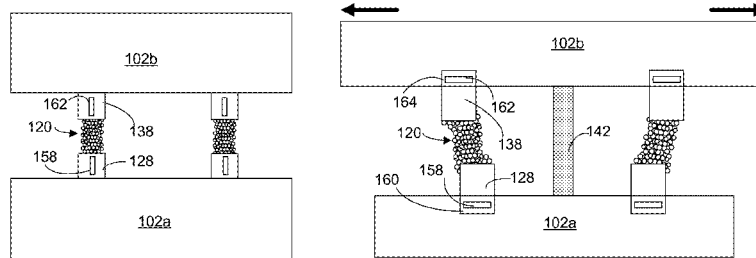
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(57)

ABSTRACT

Embodiments of the present disclosure are directed to integrated circuit (IC) package assemblies with magnetic contacts, as well as corresponding fabrication methods and systems incorporating such magnetic contacts. A first IC substrate may have a first magnet coupled with a first electrical routing feature. A second IC substrate may have a second magnet coupled with a second electrical routing feature. The magnets may be embedded in the IC substrates and/or electrical routing features. The magnets may generate a magnetic field that extends across a gap between the first and second electrical routing features. Electrically conductive magnetic particles may be applied to one or both of the IC substrates to form a magnetic interconnect structure that extends across the gap. In some embodiments, magnetic contacts may be demagnetized by heating the magnets to a corresponding partial demagnetization temperature (PDT) or Curie temperature. Other embodiments may be described and/or claimed.

21 Claims, 10 Drawing Sheets



(52) U.S. Cl.

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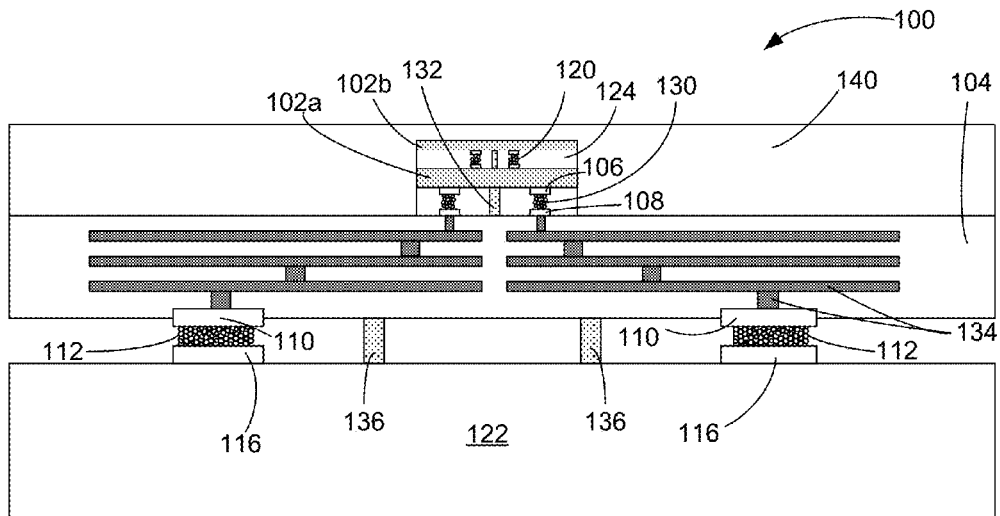


FIG. 1A

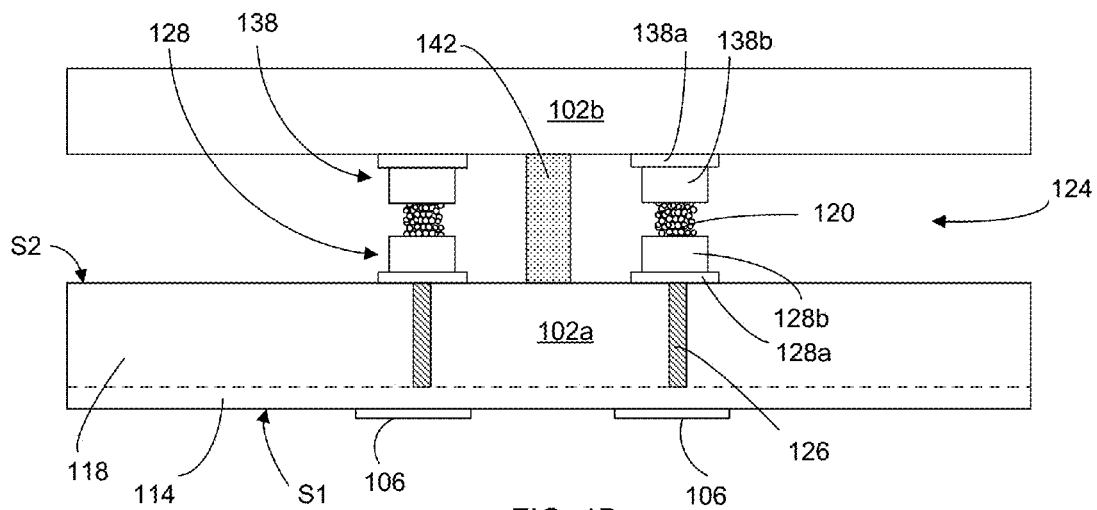


FIG. 1B

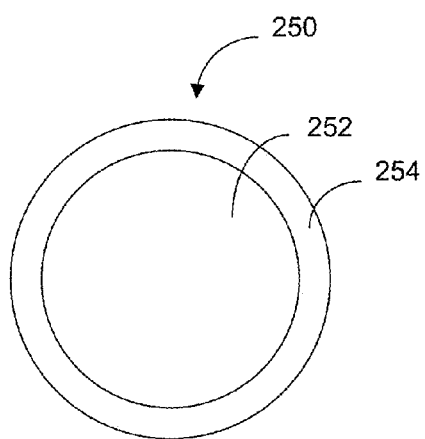


FIG. 2A

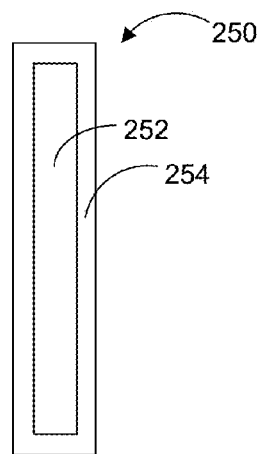


FIG. 2B

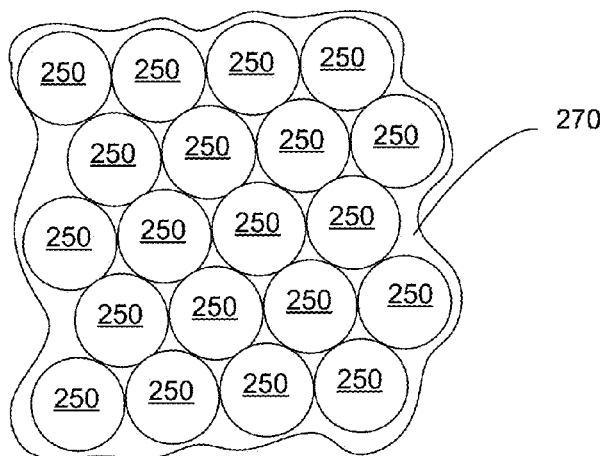


FIG. 2C

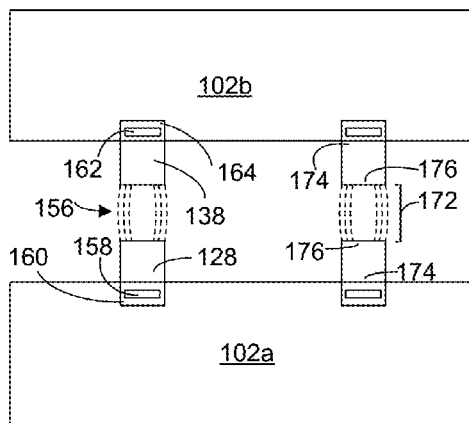


FIG. 3A

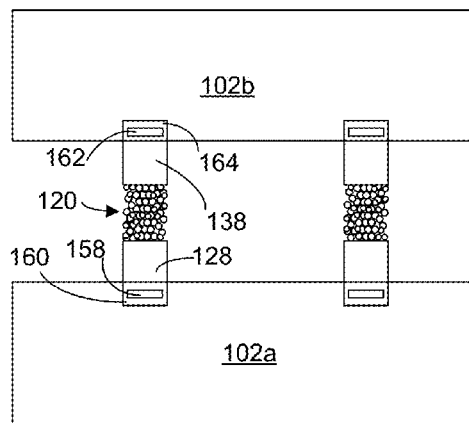


FIG. 3B

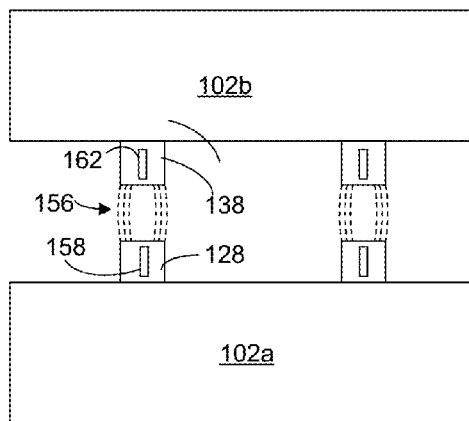


FIG. 3C

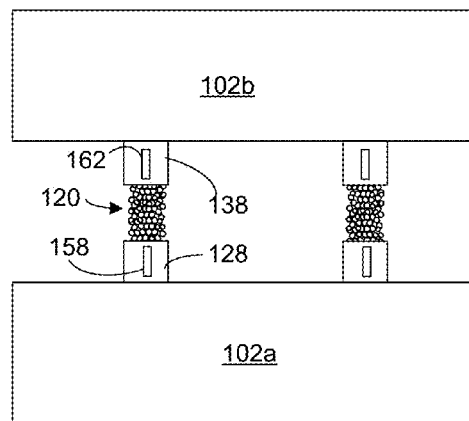


FIG. 3D

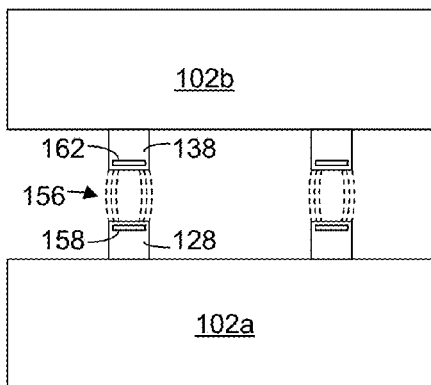


FIG. 3E

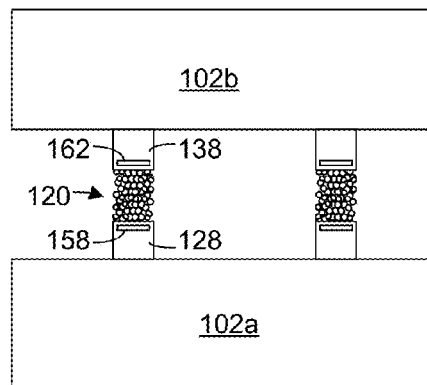


FIG. 3F

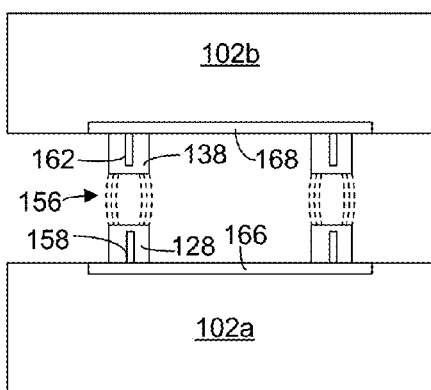


FIG. 3G

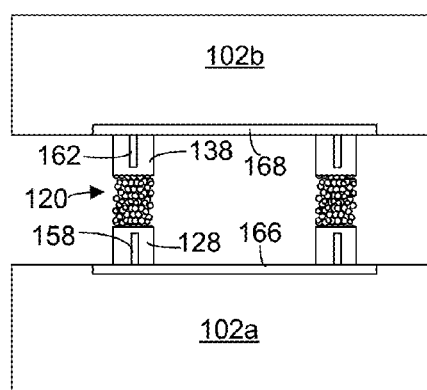


FIG. 3H

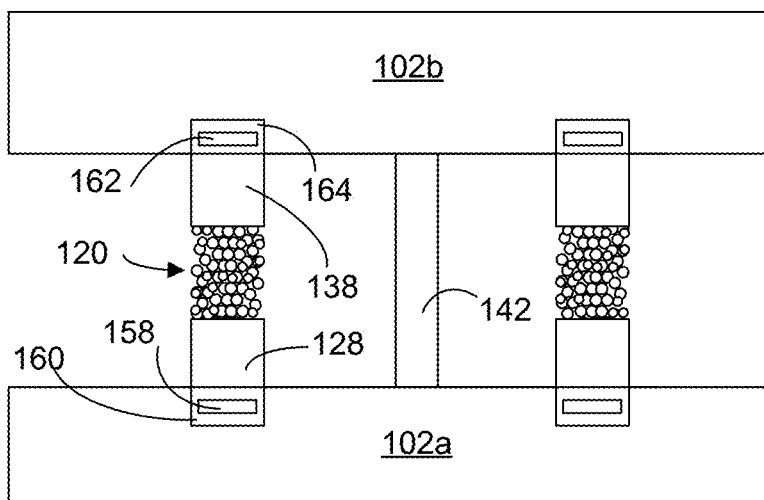


FIG. 4A

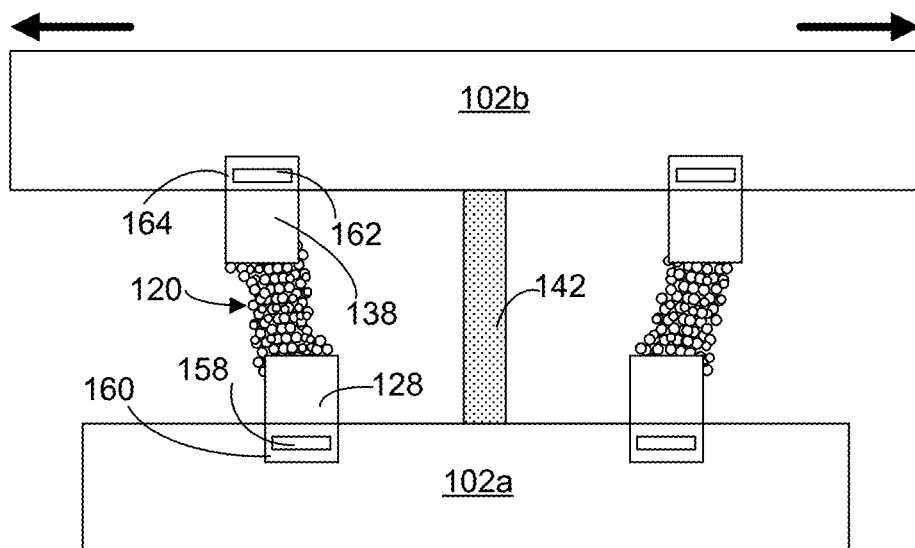


FIG. 4B

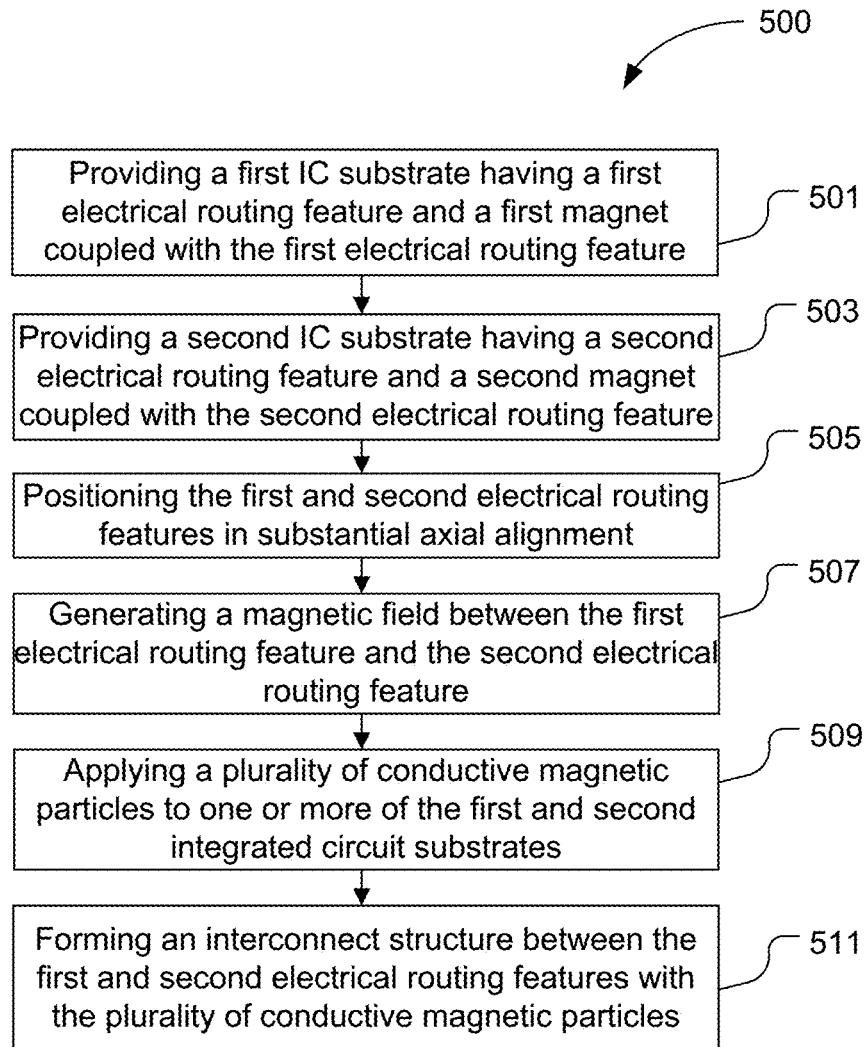


FIG. 5

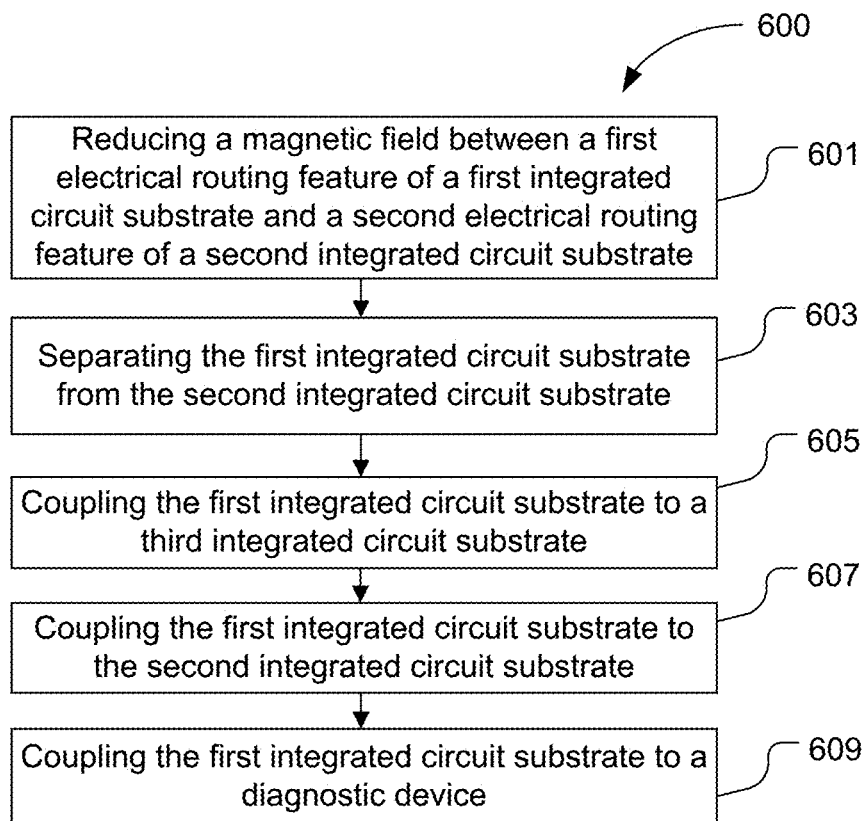


FIG. 6

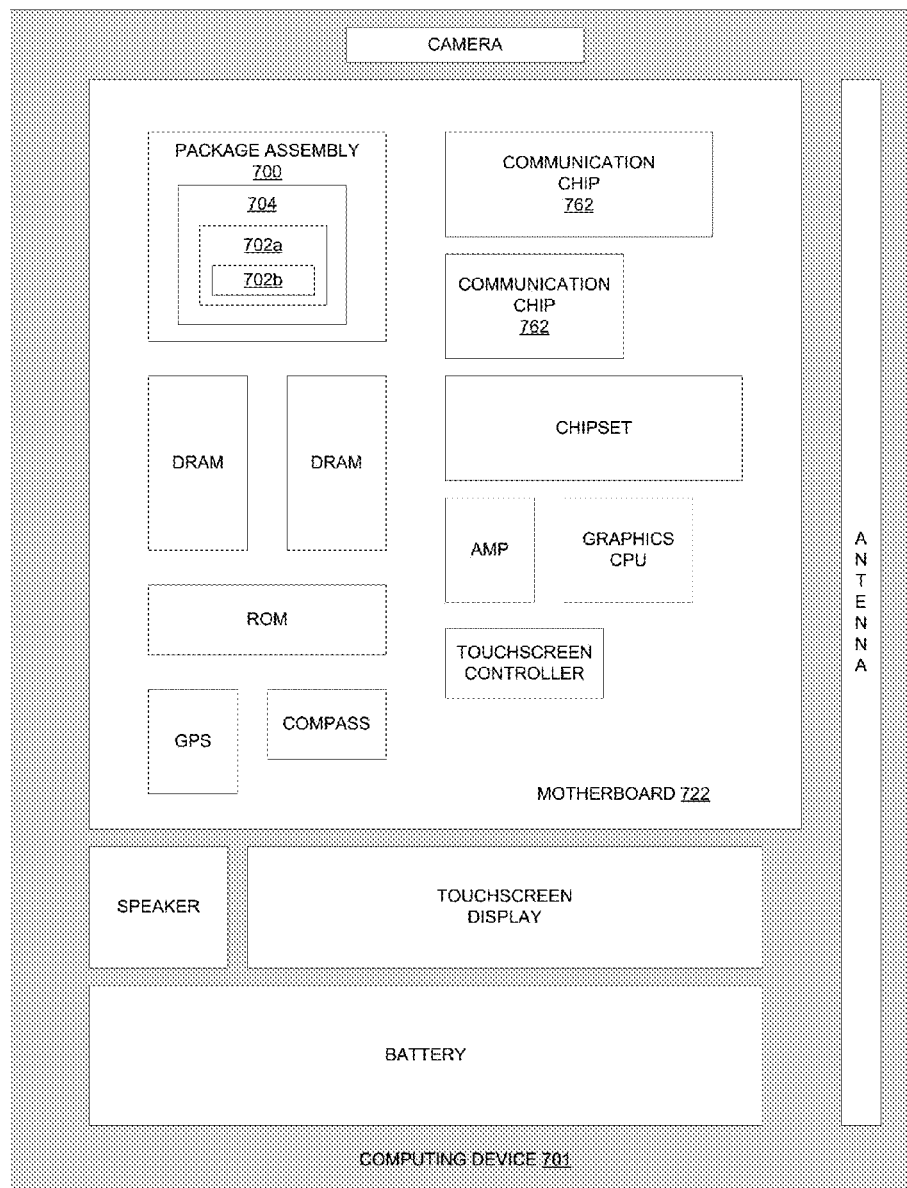


FIG. 7

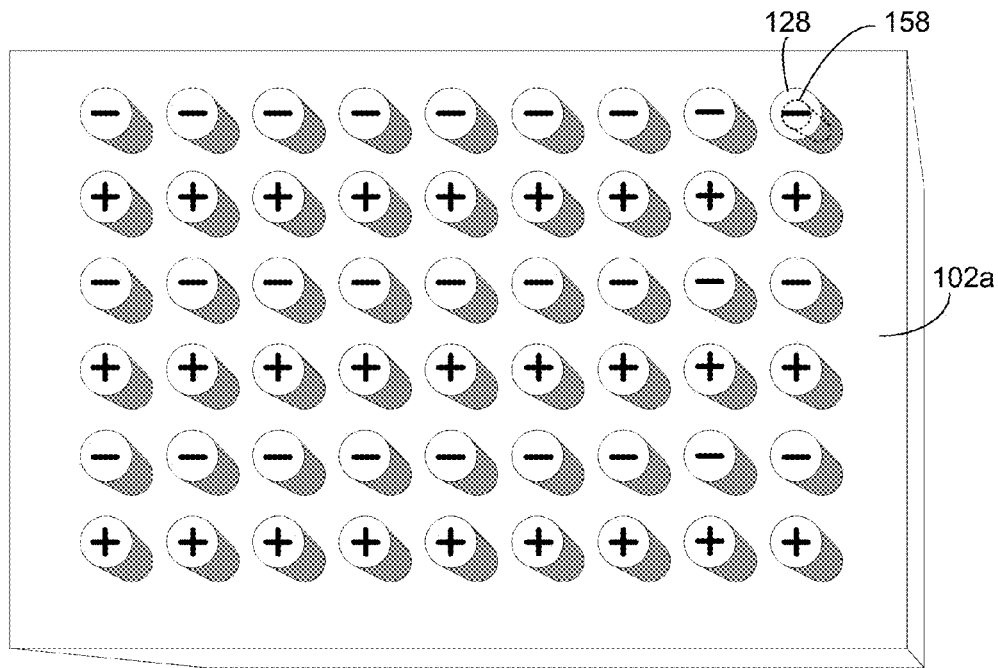


FIG. 8A

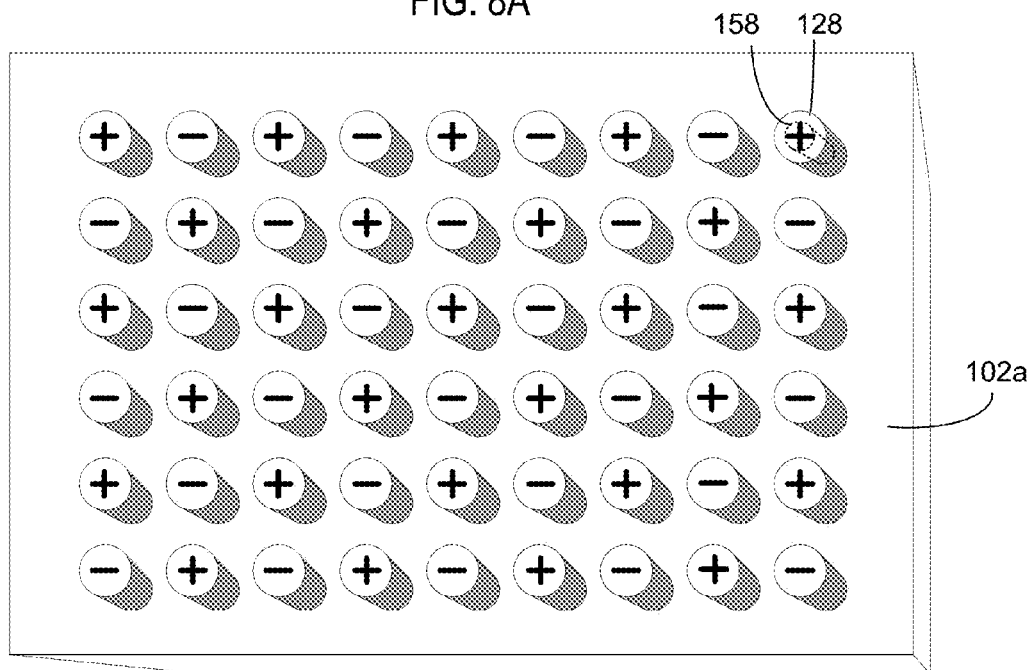


FIG. 8B

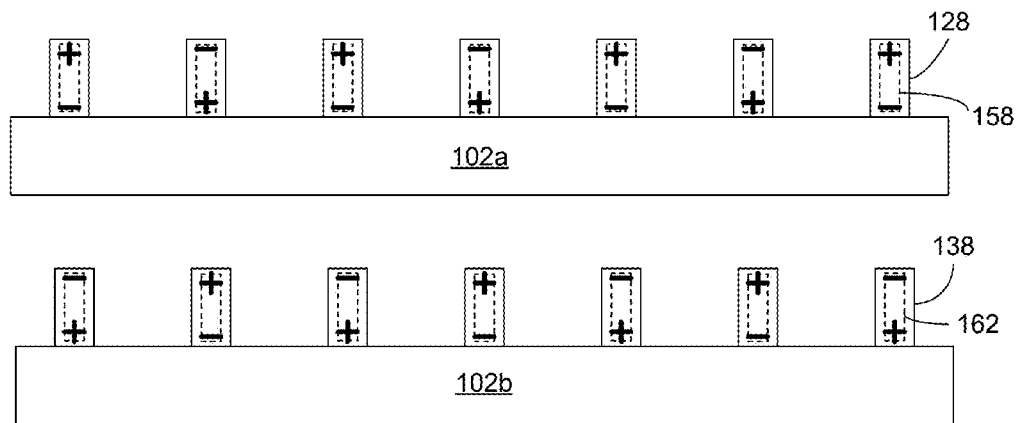


FIG. 8C

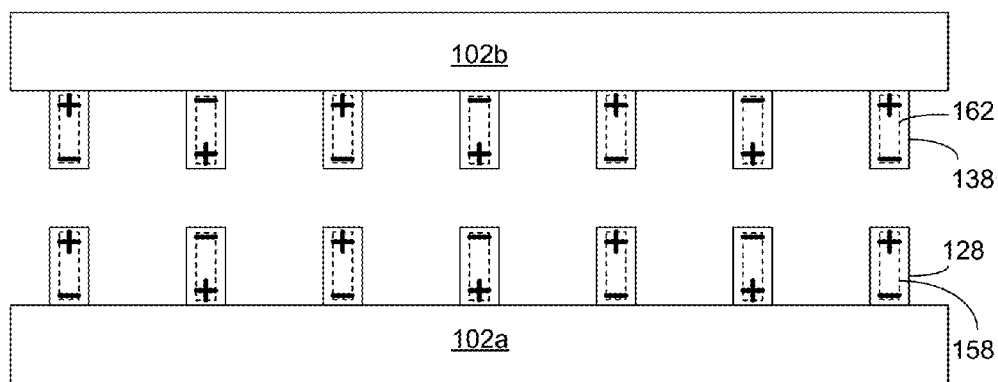


FIG. 8D

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MAGNETIC CONTACTS**RELATED APPLICATIONS**

This application is a continuation of U.S. patent application Ser. No. 13/965,746, entitled "MAGNETIC CONTACTS," filed on Aug. 13, 2013, which is hereby incorporated by reference in its entirety for all purposes.

FIELD

Embodiments of the present disclosure generally relate to the field of integrated circuits, and more particularly, to techniques and configurations for integrated circuit (IC) package assemblies and various other devices with electric contacts.

BACKGROUND

Conventional IC package assemblies include components constructed from various materials with different coefficients of thermal expansion (CTE), including plastics, metals, and silicon. Where two components are connected by solder joints, a CTE mismatch between the two components can result in movement upon heating and cooling, which in turn produces a shear strain on the solder joints. Underfill is used in some IC package assemblies to reduce the CTE mismatch. Nonetheless, repeated thermal fluctuations can lead to fatigue fractures in the solder joints, underfill, and other components.

BRIEF DESCRIPTION OF THE DRAWINGS

Embodiments will be readily understood by the following detailed description in conjunction with the accompanying drawings. To facilitate this description, like reference numerals designate like structural elements. Embodiments are illustrated by way of example and not by way of limitation in the figures of the accompanying drawings.

FIGS. 1A-1B illustrate a schematic cross-section side view of an example integrated circuit (IC) package assembly and portions thereof, in accordance with various embodiments.

FIGS. 2A-2C illustrate schematic views of conductive magnetic particles, in accordance with some embodiments.

FIGS. 3A-3H illustrate schematic cross-section side views of IC substrates with magnetic interconnect structures, in accordance with some embodiments.

FIGS. 4A-4B illustrate a schematic cross-section side view of IC substrates with magnetic interconnect structures, in accordance with some embodiments.

FIG. 5 schematically illustrates a flow diagram for a method of magnetically coupling IC substrates, in accordance with some embodiments.

FIG. 6 schematically illustrates a flow diagram for a method of separating magnetically coupled IC substrates, in accordance with some embodiments.

FIG. 7 schematically illustrates a computing device in accordance with various embodiments.

FIGS. 8A-8D illustrate schematic views of pole orientation patterns in accordance with various embodiments.

DETAILED DESCRIPTION

Embodiments of the present disclosure describe techniques and configurations for IC substrates with magnetic contacts. In the following description, various aspects of the illustrative implementations will be described using terms commonly employed by those skilled in the art to convey the substance of their work to others skilled in the art. However,

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it will be apparent to those skilled in the art that embodiments of the present disclosure may be practiced with only some of the described aspects. For purposes of explanation, specific numbers, materials and configurations are set forth in order to provide a thorough understanding of the illustrative implementations. However, it will be apparent to one skilled in the art that embodiments of the present disclosure may be practiced without the specific details. In other instances, well-known features are omitted or simplified in order not to obscure the illustrative implementations.

In the following detailed description, reference is made to the accompanying drawings which form a part hereof, wherein like numerals designate like parts throughout unless otherwise indicated, and in which is shown by way of illustration embodiments in which the subject matter of the present disclosure may be practiced. It is to be understood that other embodiments may be utilized and structural or logical changes may be made without departing from the scope of the present disclosure. Therefore, the following detailed description is not to be taken in a limiting sense, and the scope of embodiments is defined by the appended claims and their equivalents.

For the purposes of the present disclosure, the phrase "A and/or B" means (A), (B), or (A and B). For the purposes of the present disclosure, the phrase "A, B, and/or C" means (A), (B), (C), (A and B), (A and C), (B and C), or (A, B and C).

The description may use perspective-based descriptions such as top/bottom, in/out, over/under, and the like. Such descriptions are merely used to facilitate the discussion and are not intended to restrict the application of embodiments described herein to any particular orientation.

The description may use the phrases "in an embodiment," or "in embodiments," which may each refer to one or more of the same or different embodiments. Furthermore, the terms "comprising," "including," "having," and the like, as used with respect to embodiments of the present disclosure, are synonymous.

The term "coupled with," along with its derivatives, may be used herein. "Coupled" may mean one or more of the following. "Coupled" may mean that two or more elements are in direct physical or electrical contact. However, "coupled" may also mean that two or more elements indirectly contact each other, but yet still cooperate or interact with each other, and may mean that one or more other elements are coupled or connected between the elements that are said to be coupled with each other. The term "directly coupled" may mean that two or elements are in direct contact.

As used herein, the "Curie temperature" of a magnet or magnetic article is the temperature at which the magnet or magnetic article loses essentially all magnetization. As used herein, the "maximum operating temperature" or "MOT" of a magnet or magnetic article is the highest temperature to which the magnet or magnetic article can be heated without becoming at least partially demagnetized. As used herein, the "partial demagnetization temperature" or "PDT" is a temperature or range of temperatures at which a magnet or magnetic article is partially demagnetized. In various embodiments, magnets/magnetic articles that are heated to their PDT may retain some of their magnetic strength (e.g., 99-50%, 75-25%, 60-40%, 50-20%, or 30-5% of original magnetic strength). In some embodiments, the reduction in magnetic strength of the magnet/magnetic article after heating to the PDT may be sufficient to cause the magnet/magnetic article to become uncoupled from an adjacent magnet/magnetic article when additional force (e.g., mechanical pulling/pushing, fluid pressure, or the like) is applied to the magnet/magnetic article. In other embodiments, the reduction in magnetic

strength of the magnet/magnetic article after heating to the PDT may be sufficient to cause the magnet/magnetic article to become uncoupled from an adjacent magnet/magnetic article without the application of additional force to the magnet/magnetic article.

In various embodiments, the phrase “a first feature formed, deposited, or otherwise disposed on a second feature,” may mean that the first feature is formed, deposited, or disposed over the second feature, and at least a part of the first feature may be in direct contact (e.g., direct physical and/or electrical contact) or indirect contact (e.g., having one or more other features between the first feature and the second feature) with at least a part of the second feature.

As used herein, the phrase “through-substrate via” or “TSV” may be used in reference to an electrically conductive through-hole that extends at least partially through a die or other semiconductor substrate/device, such as an interposer. Through-substrate vias may include through-silicon vias as well as vias through other types of substrates. Thus, the phrase “through-substrate via” or “TSV” may be used for such electrically conductive features even when the semiconductor material is composed of a material other than silicon.

The phrases “integrated circuit substrate” and “IC substrate” are used interchangeably herein. An IC substrate can be any structure configured to route electrical signals, such as input/output (I/O) signals, ground signals, and/or power signals, to and from another IC substrate. Examples of IC substrates include, but are not limited to, dies, circuit boards (e.g., printed circuit boards), interposers, and package substrates (e.g., bumpless build-up layer (BBUL) substrates, coreless substrates, laminate substrates). Some IC substrates may include one or more electrically conductive features (e.g., traces, trenches, vias, bond pads, pillars), electrically insulating materials (e.g., dielectric film, plastic, resin), and/or semiconductor materials (e.g., silicon, germanium, gallium arsenide, silicon germanium). The term “component” may also be used in reference to an IC substrate that is part of an IC package assembly or portion thereof.

Embodiments described herein provide integrated circuit (IC) package assemblies with magnetic contacts/interconnect structures, components thereof, and corresponding fabrication techniques. However, such magnetic contacts and fabrication methods may also be used to form electrical connections in a variety of other applications, as will be readily understood by those skilled in the art. As such, the present disclosure is not intended to be limited to IC circuit assemblies/components, but is intended to encompass other systems, apparatuses, and methods in which magnetic contacts as described herein are used to form electrical connections.

In various embodiments, two or more IC substrates may be coupled by an interconnect structure that includes a plurality of electrically conductive magnetic particles (ECMPs). In some embodiments, the IC substrates may have electrical routing features coupled with one or more magnets. The electrical routing features of one IC substrate may be spaced apart from corresponding electrical routing features of the other IC substrate by a gap. The magnets and/or the electrical routing features may generate magnetic fields that overlap in the gap.

The ECMPs may self-align in the magnetic field to form an interconnect structure, such as a conductive bridge, that extends across the gap from one electrical routing feature to another. In various embodiments, the ECMPs may self-align to form the interconnect structure at room temperature (e.g., 20° C. to 26° C., or 68° F. to 78° F.). In some embodiments, the ECMPs may be movably coupled together by the magnetic field, and the interconnect structures may be pliable

and/or flexible. In other embodiments, the ECMPs may be fixedly coupled together, such as by a reflow/melting process. The magnetic electrical routing features and/or the ECMPs may be configured to have a predetermined MOT, PDT, and/or Curie temperature.

In some embodiments, one or more of the IC substrates may be a package substrate, an interposer, a circuit board, or another IC package component. In other embodiments, the IC substrates may be dies. For example, one IC substrate may be a die, such as a microprocessor/CPU with one or more TSVs, and the other IC substrate may be a second die (e.g., a memory die or a memory die stack). In some embodiments, conductive magnetic particles may form a plurality of interconnect structures between the IC substrates. In various embodiments, remaining space between the IC substrates may be filled with a fluid (e.g., a gas, a liquid, or a gel). In some embodiments, underfill material may be provided between the IC substrates. In other embodiments, a relatively flexible material such as a plastic/polymer, a foam, a gel, or other suitable material may be provided between the IC substrates.

While specific implementations/configurations of magnetic interconnect structures are described herein for illustrative purposes, these implementations and configurations are not intended to be exhaustive or to limit the embodiments of the present disclosure to the precise forms disclosed. For example, magnetic interconnect structures as described herein may be implemented in various testing systems and design/debug tools related to the testing, design, or production of IC package assemblies and components thereof, and in various electronic devices having integrated circuits, as well as in IC package assemblies/components. Other equivalent modifications are possible within the scope of the present disclosure, as those skilled in the relevant art will recognize.

FIG. 1A depicts a schematic side cross-sectional view of an integrated circuit (IC) package assembly **100**, in accordance with various embodiments. FIG. 1B depicts a schematic side cross-sectional view of a die portion of IC package assembly **100**, in accordance with various embodiments.

Referring first to FIG. 1A, IC package assembly **100** may include a first die **102a**, a second die **102b** coupled with first die **102a**, a package substrate **104** coupled with first die **102a** and/or second die **102b**, and a circuit board **122** coupled with package substrate **104**. Some embodiments may lack one or more of these components. In other embodiments, IC package assembly **100** may include one or more additional components such as capacitors, additional dies, and/or other IC substrates.

In various embodiments, two or more components of IC package assembly **100** (e.g., IC substrates such as first die **102a**, second die **102b**, package substrate **104**, circuit board **122**) may be coupled together by corresponding interconnect structures. As described further herein, some or all of the interconnect structures may be magnetic interconnect structures having a plurality of electrically conductive magnetic particles (ECMPs). In some embodiments, the ECMPs may be movably coupled together by a magnetic field, and the magnetic interconnect structure may be pliable/flexible. In other embodiments, the ECMPs may be fixedly coupled together (e.g., by solderable material).

Embodiments may vary as to the number, arrangement, and type(s) of interconnect structures. While the interconnect structures illustrated in FIGS. 1A-1B are described below as magnetic interconnect structures, other embodiments may have some components that are coupled by magnetic interconnect structures and other components that are coupled by conventional interconnect structures (e.g., solder, solderable material). Still other embodiments may include two compo-

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nents coupled together by both magnetic interconnect structures and conventional interconnect structures in various combinations and arrangements.

Referring now to FIG. 1B, first die **102a** may have a first side **S1** and a second side **S2** opposite to the first side **S1**. First side **S1** may be the side of the die commonly referred to as the “active” or “top” or “front” side of the die. First side **S1** may include one or more transistors. Second side **S2** may be the side of the die commonly referred to as the “inactive” or “bottom” or “back” side of the die.

First side **S1** may include an active layer **114** with one or more transistors formed thereon. The one or more transistors may be located below the outer surface of first side **S1** and are routed to the outer surface of first side **S1** by a series of metal and oxide layers. Second side **S2** may include a semiconductor substrate **118** composed of a semiconductor material. The semiconductor substrate **118** may be composed of n-type or p-type material systems and may include, for example, a crystalline substrate formed using a bulk silicon or a silicon-on-insulator substructure.

In some embodiments, first die **102a** may include one or more through-silicon vias (TSVs) **126** formed at least partially through semiconductor substrate **118**. First side **S1** of first die **102a** may include electrical routing features **106**. In some embodiments, electrical routing features **106** may be bond pads. Second side **S2** may also include one or more electrical routing features **128**. In some embodiments, electrical routing features **128** may be TSV pads coupled to corresponding TSVs **126**. TSVs **126** may be configured to route electrical signals between the active layer **114** on first side **S1** and the electrical routing features **128** on second side **S2** of die **102a**.

Some embodiments may include a second die **102b** with one or more electrical routing features **138**. In some embodiments, second die **102b** may include a plurality of dies, additional electrical routing features, and/or TSVs. Other embodiments may lack a second die **102b**.

Electrical routing features **106/128/138** may have one or more electrically conductive pads, bumps, pillars, and/or other such structures, alone or in any combination. For example, as illustrated in FIG. 1B, electrical routing features **138** may include conductive pillars **138b** formed on conductive pads **138a**, and electrical routing features **128** may include conductive pillars **128b** formed on conductive pads **128a**. In various embodiments, electrical routing features **106/128/138** may include one or more of nickel, palladium, platinum, tin, silver, gold, copper, or other metals, alone or in any combination. For example, in some embodiments, conductive pillars **128b/138b** may be copper pillars.

Electrical routing features **138** of second die **102b** may be coupled with the electrical routing features **128** of first die **102a** by interconnect structures **120**. In various embodiments, interconnect structures **120** may be magnetic interconnect structures having a plurality of conductive magnetic particles, as further described with reference to FIGS. 2A-B and 3A-H. In other embodiments, one or more of the interconnect structures **120** may be formed with solderable material (e.g., solder paste, solder balls). In various embodiments, interconnect structures **120** may have magnetic particles and solderable material around/within the magnetic particles.

In various embodiments, first die **102a** and second die **102b** may be singulated dies. In some embodiments, first die **102a** and/or second die **102b** may be a wafer (or portion thereof) having two or more dies formed thereon. In other embodiments, first die **102a** and/or second die **102b** may include two or more dies arranged in a stack. In various embodiments, first die **102a** and/or second die **102b** may be a primary logic die.

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In other embodiments, first die **102a** and/or second die **102b** may be configured to function as memory, an application specific circuit (ASIC), a processor, or some combination thereof. In some embodiments, first die **102a** may be a CPU/processor and second die **102b** may be one or more memory dies. Some embodiments may lack a second die **102b**. In other embodiments, one or more additional dies may be coupled with first die **102a**, second die **102b**, and/or package substrate **104**.

In some embodiments, second die **102b** may be coupled to first die **102a** in a front-to-back configuration (e.g., the “front” or “active” side of second die **102b** coupled to the “back” or “inactive” side **S1** of first die **102a**), as shown for example in FIG. 1B. In other configurations, first and second dies **102a/102b** may be coupled with one another in a front-to-front, back-to-back, or side-to-side arrangement. In other embodiments, second die **102b** may be arranged at an angle to first die **102a**, such as an angle in the range of 45-135 degrees, 60-120 degrees, or approximately 90 degrees.

In various embodiments, one or more spacers **142** may be provided between first die **102a** and second die **102b**. Spacer **142** may be a pillar or other structure configured to maintain a minimum distance between first and second dies **102a** and **102b**. In some embodiments, spacer **142** may be fixedly coupled with one or both of first and second dies **102a/102b**. The position of spacer **142** may vary among embodiments. In some embodiments, spacer **142** may be provided at or near the center of the outer surface of one or both dies **102a/102b**. In other embodiments, one or more spacers **142** may be provided in other locations, such as an edge, a corner, or other area. Some embodiments may lack a spacer **142**. In various embodiments, spacer(s) **142** may be made of any one or more suitable materials, including but not limited to metals, ceramics, plastics/polymers, resins, and the like. In some embodiments, spacer(s) **142** may be integral to one or both of first and second dies **102a/102b**.

In some embodiments, a space **124** between first die **102a** and second die **102b** may be filled with a fluid, such as a liquid, gas, or gel. For example, space **124** may be filled with helium or an inert gas. In other embodiments, space **124** may be fully or partially filled with a material such as an underfill material, an adhesive, or a dielectric/electrically insulating material. In some embodiments, space **124** may be partially or fully filled with a flexible material such as a plastic or polymer. In various embodiments, one or more materials or substances may be provided within space **124** to increase mechanical strength, heat dissipation, and/or adhesion.

In various embodiments, one or more of first die **102a** and second die **102b** may be embedded in an encapsulant **140**. Encapsulant **140** can be any suitable material, such as (but not limited to) an Ajinomoto Build-up Film (ABF) substrate or other build-up film, other dielectric/organic materials, resins, epoxies, polymer adhesives, silicones, acrylics, polyimides, cyanate esters, thermoplastics, and/or thermosets. In other embodiments, IC package assembly **100** may lack encapsulant **140**.

Referring again to FIG. 1A, in some embodiments, first die **102a** may be coupled to package substrate **104** by interconnect structures **130**. For example, as illustrated in FIG. 1A, package substrate **104** may have a first side with one or more electrical routing features **108** such as conductive pads or pillars, and electrical routing features **108** may be coupled with electrical routing features **106** by interconnect structures **130**. A second opposite side of package substrate **104** may have one or more electrical routing features **110**. Interconnect structures **112** may couple electrical routing features **110** to corresponding electrical routing features **116** on circuit board

122. In various embodiments, electrical routing features **110** may be arranged in a ball grid array (BGA) or other configuration. In some embodiments, one or more spacers **132** may be provided between first die **102a** and package substrate **104**.

In various embodiments, one or more of interconnect structures **112/120/130** may be magnetic interconnect structures having a plurality of conductive magnetic particles, as further described with reference to FIGS. 2A-B and 3A-H. In some embodiments, one or more of interconnect structures **112/120/130** may include magnetic particles and solderable material around/within the magnetic particles. In other embodiments, one or more of the interconnect structures **112/120/130** may be a conventional interconnect structure (e.g., bump, pillar, ball) formed with any of a wide variety of materials including, for example, metals, alloys, solderable material, or combinations thereof. Other embodiments may lack one or more of interconnect structures **112/120/130**. For example, in some embodiments, first die **102a** may be embedded in package substrate **104**, and IC package assembly **100** may lack interconnect structures **130**. Spacing/pitch of features such as electrical routing features **106/128/138** and die interconnects **112/120/130** may vary among embodiments. In some embodiments, the distance between adjacent electrical routing features **106/128/138** may be in the range of 30-80 μm , 40-100 μm , less than 40 μm , or more than 100 μm .

Package substrate **104** may have conductive features **134**, such as traces, trenches, and/or vias, formed therein to route electrical signals between the first/second die **102a/102b** and circuit board **122** and/or other electrical components external to the IC package assembly **100**.

In some embodiments, package substrate **104** may be a coreless substrate. For example, in various embodiments package substrate **104** may be a bumpless build-up layer (BBUL) assembly that includes a plurality of “bumpless” build-up layers. As used herein, “bumpless build-up layers” may refer to layers of substrate and components embedded therein without the use of solder or other attaching means that may be considered “bumps.” In various embodiments, one or more build-up layers described herein may have material properties that may be altered and/or optimized for reliability, warpage reduction, and so forth. In other embodiments, package substrate **104** may be an epoxy-based laminate substrate having a core and/or build-up layers such as, for example, an Ajinomoto Build-up Film (ABF) substrate. In other embodiments, package substrate **104** may include other suitable materials such as one or more polymers, ceramic, glass, or semiconductor materials. In some embodiments, package substrate **104** may be an interposer.

In various embodiments, circuit board **122** may be a printed circuit board (PCB) composed of an electrically insulative material such as an epoxy laminate. For example, the circuit board **122** may include electrically insulating layers composed of materials such as, for example, polytetrafluoroethylene, phenolic cotton paper materials such as Flame Retardant 4 (FR-4), FR-1, cotton paper and epoxy materials such as CEM-1 or CEM-3, or woven glass materials that are laminated together using an epoxy resin prepreg material. In other embodiments, the circuit board **122** may be composed of other suitable materials.

Some portions/features of circuit board **122** may not be depicted in FIG. 1A. In various embodiments, the circuit board **122** may include other electrical devices coupled to the circuit board that are configured to route electrical signals to or from first/second die **102a/102b** through the circuit board **122**. In some embodiments, circuit board **122** may include structures such as traces, trenches, and/or vias formed therein to route electrical signals through the circuit board **122**. In

some embodiments, the circuit board **122** may be a mother-board (e.g., motherboard **722** of FIG. 7). In some embodiments, one or more spacers **136** may be provided between package substrate **104** and circuit board **122**. In various embodiments, spacers **132/136** may implemented/configured in the same or similar manner as described for spacer(s) **142**.

FIGS. 2A-2C illustrate schematic views of conductive magnetic particles, in accordance with some embodiments. FIG. 2A illustrates a schematic side cross-section view of a magnetic particle **250** with a magnetic core **252** and an electrically conductive coating **254**. Magnetic core **252** may include any one or more suitable ferromagnetic/ferromagnetic materials, including but not limited to iron, nickel, cobalt, rare-earth metals, lodestone, ferrites, ferrofluids, and alloys/composites that include one or more ferromagnetic/ferromagnetic materials (e.g., samarium-cobalt). In some embodiments, magnetic core **252** may be a neodymium magnet. In some embodiments, magnetic core **252** may include any one or more of the materials shown below in Table 1.

TABLE 1

| Material | Curie Temperature (K) | Curie Temperature (C.) |
|--|-----------------------|------------------------|
| Iron (Fe) | 1043 | 769.85 |
| Cobalt (Co) | 1400 | 1126.85 |
| Nickel (Ni) | 631 | 357.85 |
| Gadolinium (Gd) | 292 | 18.85 |
| Dysprosium (Dy) | 88 | -185.15 |
| MnBi | 630 | 356.85 |
| MnSb | 587 | 313.85 |
| CrO ₂ | 386 | 112.85 |
| MnAs | 318 | 44.85 |
| EuO | 69 | -204.15 |
| Iron(III) oxide (Fe ₂ O ₃) | 948 | 674.85 |
| Iron(II, III) oxide (FeOFe ₂ O ₃) | 858 | 584.85 |
| NiOFe ₂ O ₃ | 858 | 584.85 |
| CuOFe ₂ O ₃ | 728 | 454.85 |
| MgOFe ₂ O ₃ | 713 | 439.85 |
| MnOFe ₂ O ₃ | 573 | 299.85 |
| Y ₃ Fe ₅ O ₁₂ | 560 | 286.85 |

Electrically conductive coating **254** may include one or more conductive metals, alone or in any suitable combination (e.g., metal alloys. In some embodiments, electrically conductive coating **254** may include a metal that is substantially resistant to oxidation (e.g., palladium, platinum, gold). In other embodiments, electrically conductive coating **254** may include a metal that forms conductive oxides upon oxidation (e.g., silver). In some embodiments, electrically conductive coating **254** may have two or more layers.

Other embodiments may lack electrically conductive coating **254**. For example, in various embodiments, the magnetic core **252** may be electrically conductive. In other embodiments, magnetic particles **250** that lack an electrically conductive coating **252** and are not electrically conductive may be provided as a suspension in a medium **170** (e.g., a viscous liquid or gel) that is electrically conductive and allows the magnetic particles **250** to move/self-align when placed in a magnetic field (see e.g., FIG. 2C). Alternatively, magnetic particles **250** with an electrically conductive coating **252** or electrically conductive magnetic core **252** may be provided as a suspension in a medium **170** that is either electrically conductive or electrically non-conductive. In other embodiments, magnetic particles **250** may be provided in the form of a dust, a powder, or the like.

The shape, size, and other characteristics of the magnetic particles may vary among embodiments. While FIG. 1A

shows a generally spherical/spheroid magnetic particle **250**, other magnetic particles **250** may have other shapes. Examples include, but are not limited to, oblong, cylindrical/rod/disk-shaped, rectangular, pyramidal, cubic, cuboidal, conical, and irregularly-shaped magnetic particles **250**. In some embodiments, as illustrated in FIG. 2B, magnetic particles **250** may have an elongated shape. Some magnetic particles may be relatively flat, which may provide improved contact with outer surfaces of electrical routing features. The size(s) of magnetic particles **250** may vary among embodiments, as further described below with reference to FIGS. 3A-3H.

FIGS. 3A-3H illustrate schematic cross-section side views of IC substrates with magnetic interconnect structures, in accordance with some embodiments. As shown in FIGS. 3A-3H, first die **102a** may have one or more electrical routing features **128** coupled with one or more magnets **158**. Second die **102b** may have one or more electrical routing features **138** coupled with one or more magnets **162**. Each of the electrical routing features **128/138** may have a base portion **174** and a top portion **176** (FIG. 3A). In some embodiments, electrical routing features **128/138** may be pillars, conductive pads, or some combination thereof, and may have any suitable size and shape.

Magnets **158/162** may include any suitable ferromagnetic/ferromagnetic material, including but not limited to iron, nickel, cobalt, rare-earth metals, lodestone, ferrites, ferrofluids, and alloys/composites that include one or more ferromagnetic/ferromagnetic materials (e.g., samarium-cobalt). In some embodiments, magnets **158/162** may be neodymium magnets. In some embodiments, magnets **158/162** may include any one or more of the materials shown below in Table 2.

TABLE 2

| Material | Curie Temperature (K) | Curie Temperature (C.) |
|--|-----------------------|------------------------|
| Iron (Fe) | 1043 | 769.85 |
| Cobalt (Co) | 1400 | 1126.85 |
| Nickel (Ni) | 631 | 357.85 |
| Gadolinium (Gd) | 292 | 18.85 |
| Dysprosium (Dy) | 88 | -185.15 |
| MnBi | 630 | 356.85 |
| MnSb | 587 | 313.85 |
| CrO ₂ | 386 | 112.85 |
| MnAs | 318 | 44.85 |
| EuO | 69 | -204.15 |
| Iron(III) oxide (Fe ₂ O ₃) | 948 | 674.85 |
| Iron(II, III) oxide (FeOFe ₂ O ₃) | 858 | 584.85 |
| NiOFe ₂ O ₃ | 858 | 584.85 |
| CuOFe ₂ O ₃ | 728 | 454.85 |
| MgOFe ₂ O ₃ | 713 | 439.85 |
| MnOFe ₂ O ₃ | 573 | 299.85 |
| Y ₃ Fe ₅ O ₁₂ | 560 | 286.85 |

Magnets **158/162** may have opposing first and second poles (e.g., north and south). In some embodiments, magnets **158** and **162** may be arranged in opposite orientations relative to the corresponding electrical routing feature **128/138**. For example, magnets **158** may be oriented with first poles extending toward the top portion **176** of corresponding electrical routing features **128**, and magnets **162** may be oriented with second poles extending toward the top portion **176** of corresponding electrical routing features **138**. Alternatively, magnets **158** may be oriented with second poles extending toward the top portion **176** of corresponding electrical routing features **128**, and magnets **162** may be oriented with first

poles extending toward the top portion **176** of corresponding electrical routing features **138**. In some embodiments, some of the magnets **158** may be oriented with first poles extending toward the top portion **176**, other magnets **158** may be oriented with second poles extending toward the top portion **176**, and each magnet **162** may have an orientation opposite to that of the corresponding magnet **158**.

The first and second dies **102a** and **102b** may be positioned such that an electrical routing feature **128** of first die **102a** and a corresponding electrical routing feature **138** of second die **102b** are axially aligned and spaced apart by a gap **172** (FIG. 3A). Corresponding magnets **158** and **162** may collectively generate a magnetic field **156** that extends across the gap **172** (FIGS. 3A, 3C, 3E, 3F). In some embodiments, when electrical routing features **128** and **138** are positioned in substantial axial alignment and substantial proximity, magnetic fields generated by each of magnets **158** and **162** may meet or overlap to form magnetic field **156**. These magnetic fields may be complimentary and/or additive due to the opposite orientations of corresponding magnets **158** and **162** (e.g., north-to-south, north-to-south).

In some embodiments, one or more of the magnets may be embedded in the IC substrate(s). For example, magnets **158/162** may be embedded in dies **102a/102b** (FIGS. 3A-B). In some embodiments, magnets **158/162** may be coupled with an electrically conductive material **164**, such as a layer or coating of a metal. Electrically conductive material **164** may in turn be conductively coupled with the corresponding electrical routing feature **128/138**.

In other embodiments, one or more of the magnets may be embedded in the electrical routing features. For example, in some embodiments, magnets **158/162** may be disposed within corresponding electrical routing features **128/138** and may extend lengthwise/axially from base portion **174** to top portion **176** (FIGS. 3C-D). In other embodiments, magnets **158/162** may be disposed within the top portions **174** of electrical routing features **128/138** (FIGS. 3E-F) or the base portions **176**. In various embodiments, embedding the magnets within the electrical routing features (e.g., into pillars) may provide a stronger and/or more localized magnetic field within the gap between the electrical routing features. In some embodiments, positioning the magnets proximal to the gap, such as on or near the top portions of the electrical routing features, may enhance the magnetic field within the gap.

In some embodiments, one or more IC substrates may include a magnetic bus, in which two magnets are coupled with a third magnet. For example, as illustrated in FIGS. 3E-F, first die **102a** may have electrical routing features **128** with corresponding magnets **158**. A third magnet **166** may be coupled with two or more of the magnets **158**. In some embodiments, the third magnet **166** may be embedded in the IC substrate (e.g., embedded in first die **102a**). In other embodiments, the third magnet **166** may be coupled to an outer surface of the IC substrate (e.g., coupled to an outer surface of first die **102a**). Similarly, the second IC substrate (e.g., second die **102b**) may have a third magnet **168** coupled with two or more of the magnets **162**.

In various embodiments, magnets **158/162** may be arranged in different orientations to form a pole orientation pattern. FIGS. 8A-8D illustrate embodiments of IC assembly components with various pole orientation patterns. While magnets **158/162** are shown embedded within corresponding electrical routing features **128/138**, in other embodiments some or all of the magnets **158/162** may be embedded in an IC substrate (e.g., first die **102a** or second die **102b**). The pole orientation of each magnet **158/162** is indicated in FIGS.

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8A-8D by “+” and/or “-” symbols on the corresponding electrical routing feature **128/138**.

As shown in FIG. 8A, in some embodiments magnets **158** may be oriented to form an “alternating row” pole orientation pattern in which the magnets **158** of one row of electrical routing features **128** have a first orientation (e.g., north-south, or “+”) and the magnets **158** of one or more adjacent rows have a second pole orientation (e.g., south-north, or “-”). In other embodiments, magnets **158** may be oriented to form a “checkerboard” pole orientation pattern in which magnets **158** of adjacent electrical routing features **128** have different/opposite pole orientations (FIG. 8B). In any case, electrical routing features **128** may be arranged in rows, concentric circles/rectangles, or any other suitable configuration. Therefore, embodiments may vary as to the arrangement of electrical routing features **128/138**, pole orientation pattern of magnets **158/162**, and combinations thereof.

In some embodiments, magnets **162** of a second component (e.g., second die **102b**) may be oriented to form a pole orientation pattern that is complementary to the pole orientation pattern of the first component (e.g., first die **102a**; FIG. 8C). In some embodiments, a complementary pole orientation pattern may be a mirror image of the other pole orientation pattern, with corresponding magnets **158** and **162** having opposite pole orientations. As a result, when the first and second components (e.g., first and second dies **102a**, **102b**) are positioned to be coupled together, corresponding magnetic contacts **158** and **162** may have the same or similar pole alignment (e.g., “+” to “-” and “+” to “-”, or “-” to “+” and “-” to “+”; FIG. 8D). In various embodiments, orienting magnets **158/162** to form complementary pole orientation patterns may help to facilitate alignment of components (e.g., first die **102a** and second die **102b**), increase speed of alignment/fabrication, and/or reduce misalignment.

While the IC substrates of FIGS. 3A-3H and 8A-8D are shown as dies, magnets **158/162/166/168** may be implemented in the same or similar manner with other IC substrates such as package substrates (e.g., package substrate **104**), circuit boards (e.g., circuit board **122**), and other types of IC substrates. For example, magnets **158/162/166/168** may be embedded any one or more of those IC substrates and/or their electrical routing features (e.g., electrical routing features **108**, **110**, **116**).

Magnetic particles may self-align in the magnetic field to bridge the gap between corresponding electrical routing features, thereby forming a magnetic interconnect structure. As shown for example in FIGS. 3B, 3D, 3F, and 3H, interconnect structures **120** may be formed in the magnetic field **156** by a plurality of magnetic particles (e.g., **250**; FIGS. 2A-C), which may be electrically conductive.

In some embodiments, the magnetic particles may have an average diameter in the range of 0.1% to 10% of the height of the gap between corresponding electrical routing features. For example, magnetic particles **250** may have average diameters in the range of 0.1% to 10% of the height of gap **172**. In some embodiments, the gap (e.g., gap **172**) may have a height in the range of 10-50 μm . In other embodiments, magnetic particles **250** may have average diameters in the range of 10 nm to 5 μm , 1 μm to 50 μm , 100 nm to 1 μm , 50 nm to 500 nm, or 100 nm to 300 nm. In various embodiments, the magnetic particles may be movably coupled together by the magnetic fields, resulting in magnetic interconnect structures that are pliable/flexible and resistant to fatigue failures during repeated cycles of heating and cooling. In some embodiments, one or more spacers may be provided between IC substrates that are coupled with magnetic interconnect structures. These spacers may be configured to maintain a prede-

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termined distance between the IC substrates while allowing expansion/contraction of the IC substrates. In some embodiments, the spacer(s) may be fixedly coupled with the IC substrates, and the IC substrates may expand and contract outwardly from the spacer.

FIGS. 4A-4B illustrate a schematic cross-section side view of IC substrates coupled with magnetic interconnects and a spacer, in accordance with various embodiments. In the illustrated embodiment, first and second dies **102a** and **102b** are coupled with interconnect structures **120**, which are formed by a plurality of magnetic particles that are movably coupled together by a magnetic field generated by magnets **162** and **158**. In some embodiments, a spacer **142** may be fixedly coupled with first and/or second dies **102a** and **102b**. In various embodiments, a spacer (e.g., spacer **142**) may be coupled with one or more IC substrates (e.g., dies, circuit boards, package substrates) using any suitable material or technique, including but not limited to adhesives, heating/pressure, and/or soldering.

As second die **102b** expands outwardly from spacer **142** in response to heating, the positions of electrical routing features **138** may be shifted with respect to electrical routing features **128** (FIG. 4B). Because the magnetic particles are movably coupled and retained between the electrical routing features **128/138** by magnetic forces, the magnetic particles may move relative to one another while maintaining a connection between the corresponding electrical routing features. In addition, the stress/strain induced by the outward expansion may be at least partially relieved by the movement of the magnetic particles, allowing the interconnect structure to flex/deform over numerous thermal cycles with less fatigue than rigid interconnect structures (e.g., solder).

In various embodiments, spacer **142** may be configured to dissipate heat. In some embodiments, spacer **142** may be coupled with a heat sink (not shown), and may be configured to conduct heat away from dies **102a/102b**. In other embodiments, spacer **142** may be used as a conductive connection. For example, spacer **142** may be formed with one or more metals or other electrically conductive materials. Alternatively, one or more magnets (not shown) may be positioned within or proximal to spacer **142** to generate a magnetic field around spacer **142**, and a plurality of magnetic particles may form a magnetic interconnect structure on or around spacer **142** within the magnetic field.

In other embodiments, magnetic interconnect structures as described herein may be implemented in various testing systems, design/debug tools, and other devices related to the testing, design, or production of IC package assemblies and components thereof. In some embodiments, magnetic interconnect structures as described herein may be implemented for use as thermal fuses. For example, the magnets (e.g., magnets **162/158**) may be designed to have a predetermined MOT, PDT, and/or Curie temperature. Similarly, in various embodiments the magnetic particles **250** may be designed to have a predetermined MOT/PDT/Curie temperature. In some embodiments the magnets may have a higher PDT temperature than the magnetic particles. In other embodiments, the magnetic particles may have a higher MOT/PDT/Curie temperature than the magnets. In still other embodiments, one of the magnets may have a higher MOT/PDT/Curie temperature than the other magnet.

In any case, the magnetic particles may be used to form magnetic interconnect structures (e.g., **112/120/130**) between two IC substrates (e.g., dies **102a** and **102b**, die **102a** and package substrate **104**, package substrate **104** and circuit board **122**, etc.). Heating one or more of the magnets and/or the magnetic particles to the corresponding PDT/Curie tem-

perature may result in a loss of magnetism and disconnection of the magnetic interconnect structure from one or both of the electrical routing features. In some embodiments, the magnetic particles of the magnetic interconnect structure may lose sufficient magnetism to detach from the electrical routing features and/or one another. In other embodiments, one of the magnets may lose magnetism and the magnetic particles may become uncoupled from the corresponding electrical routing feature. In that case, some or all of the magnetic particles may remain coupled with the electrical routing feature of the other IC substrate, or with another electrical routing feature and/or magnetic interconnect structure.

In some embodiments, the PDT and/or Curie temperature of one or more of the first magnet, the second magnet, and the conductive magnetic particles may be below a solder reflow temperature. For example, in some embodiments, the PDT of one or more of the first magnet, the second magnet, and the conductive magnetic particles may be in the range of 100-250° C., 110-240° C., 120-230° C., 100-120° C., 110-130° C., 120-140° C., 130-150° C., 140-160° C., 150-170° C., 160-180° C., 170-190° C., 180-200° C., 190-210° C., 200-220° C., 210-230° C., 220-240° C., 230-250° C., 240-260° C., 250-270° C., 260-280° C., 270-290° C., 280-300° C., 290-310° C., 300-320° C., 310-330° C., 320-340° C., 330-350° C., 340-360° C., 350-370° C., 360-380° C., 370-390° C., 380-400° C., 390-410° C., 400-420° C., 410-440° C., 420-440° C., 430-450° C., 440-460° C., or 440-460° C. In other embodiments, the Curie temperature of one or more of the first magnet, the second magnet, and the conductive magnetic particles may be in the range of 100-250° C., 110-240° C., 120-230° C., 100-120° C., 110-130° C., 120-140° C., 130-150° C., 140-160° C., 150-170° C., 160-180° C., 170-190° C., 180-200° C., 190-210° C., 200-220° C., 210-230° C., 220-240° C., 230-250° C., 240-260° C., 250-270° C., 260-280° C., 270-290° C., 280-300° C., 290-310° C., 300-320° C., 310-330° C., 320-340° C., 330-350° C., 340-360° C., 350-370° C., 360-380° C., 370-390° C., 380-400° C., 390-410° C., 400-420° C., 410-440° C., 420-440° C., 430-450° C., 440-460° C., or 440-460° C. In some embodiments, one or more of the first magnet, the second magnet, and the conductive magnetic particles may include any one or more of the materials shown below in Table 3.

TABLE 3

| Material | Curie Temperature (K) | Curie Temperature (°C.) |
|--|-----------------------|-------------------------|
| Iron (Fe) | 1043 | 769.85 |
| Cobalt (Co) | 1400 | 1126.85 |
| Nickel (Ni) | 631 | 357.85 |
| Gadolinium (Gd) | 292 | 18.85 |
| Dysprosium (Dy) | 88 | -185.15 |
| MnBi | 630 | 356.85 |
| MnSb | 587 | 313.85 |
| CrO ₂ | 386 | 112.85 |
| MnAs | 318 | 44.85 |
| EuO | 69 | -204.15 |
| Iron(III) oxide (Fe ₂ O ₃) | 948 | 674.85 |
| Iron(II, III) oxide (FeOFe ₂ O ₃) | 858 | 584.85 |
| NiOFe ₂ O ₃ | 858 | 584.85 |
| CuOFe ₂ O ₃ | 728 | 454.85 |
| MgOFe ₂ O ₃ | 713 | 439.85 |
| MnOFe ₂ O ₃ | 573 | 299.85 |
| Y ₃ Fe ₅ O ₁₂ | 560 | 286.85 |

Thus, in some embodiments an IC substrate, component, or device may include a plurality of magnets, each coupled with a different electrical routing feature. The IC substrate may be

coupled with another IC substrate, component, or device by forming magnetic interconnect structures with magnetic particles as described herein. One of the IC substrates may be configured to monitor the connectivity status of the magnetic interconnect structures, and/or to determine whether a given pair of electrical routing features remains conductively coupled by the corresponding magnetic interconnect structure. In some embodiments, the plurality of magnets may include magnets with different PDT/Curie temperatures, and the temperature of one or both IC substrates may be monitored or assessed by determining which (if any) of the electrical routing features has become conductively uncoupled from the other IC substrate/component/device. In other embodiments, magnets with the same or similar PDT/Curie temperature may be disposed in different locations along the IC substrate, and the local temperatures of corresponding portions of the IC substrate may be monitored or assessed by determining which (if any) of the electrical routing features has become conductively uncoupled from the other IC substrate/component/device.

In some implementations, the magnets/magnetic particles may be configured to disconnect the IC substrate (e.g., second die **102b**) from the other IC substrate/component/device (e.g., first die **102a**) at a predetermined temperature to prevent overheating or heat-induced damage. In another implementation, the IC substrates/components/devices may be coupled with a plurality of magnetic interconnect structures and incorporated in a temperature monitoring device designed to be placed/worn on the skin of a human or animal. The temperature monitoring device may be configured to determine the status of the magnetic interconnect structures (e.g., conductively coupled or conductively uncoupled), and to correlate the status with a temperature. For example, the device may equate a loss of particular connection(s) or a loss of a predetermined number of connection(s) to a particular temperature or range of temperatures.

FIG. 5 schematically illustrates a flow diagram for a method of magnetically coupling IC substrates, in accordance with some embodiments. FIG. 6 schematically illustrates a flow diagram for a method of separating magnetically coupled IC substrates, in accordance with some embodiments.

Referring first to FIG. 5, method **500** may begin at block **501** with providing a first IC substrate (e.g., first die **102a**) having a first electrical routing feature (e.g., electrical routing feature **128**) and a first magnet (e.g., magnet **158**) coupled with the first electrical routing feature. At block **503**, a second IC substrate (e.g., second die **102b**) having a second electrical routing feature (e.g., electrical routing feature **138**) and a second magnet (e.g., magnet **162**) coupled with the second electrical routing feature may be provided. In various embodiments, the first and second IC substrates may be any combination of dies, package substrates, circuit boards, or other IC substrates. The electrical routing features may be formed with any suitable electrically conductive material and in any suitable shape, as described herein.

At block **505**, the first and second electrical routing features (e.g., electrical routing features **128** and **138**) may be positioned in substantial axial alignment. For example, where the first and second electrical routing features include pillars, the IC substrates may be positioned such that corresponding pillars on each of the IC substrates are in substantial axial alignment and spaced apart by a gap.

At block **507**, a magnetic field (e.g., magnetic field **156**) may be generated between the first electrical routing feature and the second electrical routing feature. In some embodiments, generating the magnetic field may include coupling a

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first magnet (e.g., magnet **158**) with the first electrical routing feature or the first IC substrate, and coupling a second magnet (e.g., magnet **162**) with the second electrical routing feature or the second IC substrate. In some embodiments, generating the magnetic field may include embedding the first magnet into the first electrical routing feature or the first IC substrate and/or embedding the second magnet into the second electrical routing feature or the second IC substrate. In some embodiments, positioning the first and second electrical routing features in substantial axial alignment may include positioning the first and second magnets in substantial axial alignment. In various embodiments, generating the magnetic field may include positioning the first and second electrical routing features in substantial proximity such that corresponding first and second magnetic fields of the first and second magnets overlap along said gap.

At block **509**, a plurality of conductive magnetic particles (e.g., magnetic particles **250**) may be applied to one or more of the first and second IC substrates. In some embodiments, the conductive magnetic particles may be applied to one or more of the first and second electrical routing features. For example, the first/second IC substrate(s) may be dipped into a reservoir that contains the conductive magnetic particles, which may cling to the first/second electrical routing features due to magnetic attraction. Alternatively, the conductive magnetic particles may be sprayed or otherwise dispensed onto the first/second IC substrates. In some embodiments, the conductive magnetic particles may be dispensed into a space (e.g., space **124**) between the first and second IC substrates. In other embodiments, the conductive magnetic particles may be dispensed into a gap (e.g., gap **172**) between the first and second electrical routing features.

At block **511**, an interconnect structure (e.g., interconnect structure **112**, **120**, **130**) may be formed between the first and second electrical routing features with the plurality of conductive magnetic particles. In some embodiments, the conductive magnetic particles may self-align to form the interconnect structure. In various embodiments, the conductive magnetic particles may be provided with a solderable material (e.g., within or surrounding the conductive magnetic particles), and forming the interconnect structure may include heating the solderable material. In other embodiments, the interconnect structure may be formed at room/ambient temperature, and the conductive magnetic particles may be movably coupled together by the magnetic field.

In various embodiments, magnetic interconnect structures may be disrupted for purposes such as testing or reworking one or more of the IC substrates. Referring now to FIG. **6**, a method **600** may be begun at block **601** with reducing a magnetic field (e.g., magnetic field **156**) between a first electrical routing feature of a IC circuit substrate (e.g., electrical routing feature **128** of die **102a**) and a second electrical routing feature of a second IC substrate (e.g., electrical routing feature **138** of second die **102b**). In some embodiments, the magnetic field may be generated by a first magnet (e.g., magnet **158**) coupled with the first electrical routing feature/IC substrate and a second magnet (e.g., magnet **162**) coupled with the second electrical routing feature/IC substrate. In various embodiments, a plurality of conductive magnetic particles (e.g., magnetic particles **250**) may be disposed in a gap (e.g., gap **172**) between the first and second electrical routing features, and reducing the magnetic field may reduce a magnetic attraction between the conductive magnetic particles and the first and second electrical routing features.

In various embodiments, reducing the magnetic field may include heating the first/second magnet(s) to a PDT and/or Curie temperature of the first/second magnet(s). In some

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embodiments, one of the magnets may have a lower PDT/Curie temperature than the other magnet, and reducing the magnetic field may include heating the magnet with the lower of the two PDT/Curie temperatures to that MOT/Curie temperature. In other embodiments, the first and second magnets may have substantially the same PDT/Curie temperature, and reducing the magnetic field may include heating one or both of the magnets to that PDT/Curie temperature. In some embodiments, reducing the magnetic field may include heating the conductive magnetic particles to a PDT/Curie temperature of the conductive magnetic particles.

At block **603**, the first IC substrate may be separated from the second IC substrate. In some embodiments, separating the first and second IC substrates may include physically pulling or pushing one of the IC substrates away from the other after reducing the magnetic field. In other embodiments, separating the first and second IC substrates may further include disconnecting a spacer and/or a conventional interconnect structure (e.g., solder) from one or more of the IC substrates.

At blocks **605**, **607**, and **609**, the first IC substrate may be coupled to a third IC substrate (block **605**), the second IC substrate (block **607**), and/or a diagnostic device (block **609**). In various embodiments, the second/third IC substrate may be a motherboard, a die/die stack, a computer, a mobile electronic device, or any other IC substrate. In some embodiments, the first IC substrate may be a chip card that is configured to be removable/replaceable without substantial damage.

In various embodiments, coupling the first IC substrate to any one or more of the third IC substrate, the second IC substrate, and the diagnostic device may include forming magnetic interconnect structures between the first IC substrate and that substrate/device. For example, in some embodiments, reducing the magnetic field may include heating the conductive magnetic particles to a PDT/Curie temperature of the conductive magnetic particles without heating the first/second magnet to the PDT/Curie temperature of the first/second magnet, and coupling the first IC substrate to the corresponding substrate/device may include forming a new magnetic interconnect with other conductive magnetic particles. In other embodiments, reducing the magnetic field may include heating the second magnet (of the second IC substrate) to a PDT/Curie temperature of the second magnet without heating the first magnet (of the first IC substrate) to the PDT/Curie temperature of the first magnet. The first IC substrate may then be coupled with the third IC substrate and/or diagnostic device by forming new magnetic interconnects with other conductive magnetic particles.

In various embodiments, reducing the magnetic field may include heating the second magnet to the PDT/Curie temperature of the second magnet, and coupling the first IC substrate with the second IC substrate may include forming conventional interconnects (e.g., solder, wire, etc.) between the first and second IC substrates. In other embodiments, reducing the magnetic field may include heating the first magnet to a PDT/Curie temperature of the first magnet, and coupling the first IC substrate with the second/third IC substrate and/or diagnostic device may include forming conventional interconnects (e.g., solder, wire, etc.) between the first IC substrate and the second/third IC substrate and/or diagnostic device. In still other embodiments, coupling the first IC substrate to any one or more other substrates/devices may include coupling additional magnets to the first/second/third IC substrates or diagnostic device and forming magnetic interconnect structures between the additional magnets.

Various operations are described as multiple discrete operations in turn, in a manner that is most helpful in under-

standing the claimed subject matter. However, the order of description should not be construed as to imply that these operations are necessarily order dependent. Embodiments of the present disclosure may be implemented into a system using any suitable hardware and/or software to configure as desired.

FIG. 7 illustrates an example computing device **701**, in accordance with various embodiments. IC package assemblies as described herein may be installed on a computing/communicating device. For example, IC package assembly **700** may be installed on a computing device **701**. IC package assembly **700** may include a first die **702a** embedded in a package substrate **704** and a second die **702b** coupled with the first die **702a**. Components, features, and/or configurations of IC package assembly **700** may be as described herein with reference to IC package assembly **100** and components thereof.

The computing device **701** may house a circuit board such as motherboard **722**. The motherboard **722** may include a number of components, including but not limited to IC package assembly **700** and at least one communication chip **762**. The IC package assembly **700** may be physically and electrically coupled to the motherboard **722** (e.g., circuit board **122** of FIG. 1A). In some implementations, communication chip(s) **762** may also be physically and electrically coupled to the motherboard **722**. In further implementations, the communication chip(s) **762** may be part of the IC package assembly **700**. In various embodiments, at least one communication chip **762** may be physically and electrically coupled to IC package assembly **700**. In further implementations, a communication chip **762** may be part of IC package assembly **700**, e.g., as an additional die on or embedded in build-up layers in IC package assembly **700**. For these embodiments, IC package assembly **700** and communication chip **762** may be disposed on the motherboard **722**. In alternate embodiments, the various components may be coupled without the employment of motherboard **722**.

In some embodiments, a die of IC package assembly **700** (e.g., first die **702a**) may be a processor of the computing device **701**. The term “processor” may refer to any device or portion of a device that processes electronic data from registers and/or memory to transform that electronic data into other electronic data that may be stored in registers and/or memory.

Depending on its applications, computing device **701** may include other components that may or may not be physically and electrically coupled to the motherboard **722**. These other components include, but are not limited to, volatile memory (e.g., dynamic random access memory, also referred to as “DRAM”), non-volatile memory (e.g., read only memory, also referred to as “ROM”), flash memory, an input/output controller, a digital signal processor (not shown), a crypto processor (not shown), a graphics processor, one or more antenna, a display (e.g., a touch screen display), a touch screen controller, a battery, an audio codec (not shown), a video codec (not shown), a global positioning system (“GPS”) device, a compass, an accelerometer (not shown), a gyroscope (not shown), a speaker, a camera, and a mass storage device (such as hard disk drive, a solid state drive, compact disk (“CD”), digital versatile disk (“DVD”))(not shown), and so forth. In various embodiments, various components may be integrated with other components to form a System on Chip (“SoC”). In further embodiments, some components, such as DRAM, may be embedded in or within IC package assembly **700**.

The communication chip(s) **762** may enable wired and/or wireless communications for the transfer of data to and from

the computing device **701**. The term “wireless” and its derivatives may be used to describe circuits, devices, systems, methods, techniques, communications channels, etc., that may communicate data through the use of modulated electromagnetic radiation through a non-solid medium. The term does not imply that the associated devices do not contain any wires, although in some embodiments they might not. The communication chip **762** may implement any of a number of wireless standards or protocols, including but not limited to Institute for Electrical and Electronic Engineers (IEEE) standards including Wi-Fi (IEEE 802.11 family), IEEE 802.16 standards (e.g., IEEE 802.16-2005 Amendment), Long-Term Evolution (LTE) project along with any amendments, updates, and/or revisions (e.g., advanced LTE project, ultra mobile broadband (UMB) project (also referred to as “3GPP2”), etc.). IEEE 802.16 compatible BWA networks are generally referred to as WiMAX networks, an acronym that stands for Worldwide Interoperability for Microwave Access, which is a certification mark for products that pass conformity and interoperability tests for the IEEE 802.16 standards. The communication chip **762** may operate in accordance with a Global System for Mobile Communication (GSM), General Packet Radio Service (GPRS), Universal Mobile Telecommunications System (UMTS), High Speed Packet Access (HSPA), Evolved HSPA (E-HSPA), or LTE network. The communication chip **762** may operate in accordance with Enhanced Data for GSM Evolution (EDGE), GSM EDGE Radio Access Network (GERAN), Universal Terrestrial Radio Access Network (UTRAN), or Evolved UTRAN (E-UTRAN). The communication chip **762** may operate in accordance with Code Division Multiple Access (CDMA), Time Division Multiple Access (TDMA), Digital Enhanced Cordless Telecommunications (DECT), Evolution-Data Optimized (EV-DO), derivatives thereof, as well as any other wireless protocols that are designated as 3G, 4G, 5G, and beyond. The communication chip **762** may operate in accordance with other wireless protocols in other embodiments.

The computing device **701** may include a plurality of communication chips **762**. For instance, a first communication chip **762** may be dedicated to shorter range wireless communications such as Wi-Fi and Bluetooth and a second communication chip **762** may be dedicated to longer range wireless communications such as GPS, EDGE, GPRS, CDMA, WiMAX, LTE, Ev-DO, and others.

In various implementations, the computing device **701** may be a laptop, a netbook, a notebook, an ultrabook, a smart phone, a computing tablet, a personal digital assistant (“PDA”), an ultra mobile PC, a mobile phone, a desktop computer, a server, a printer, a scanner, a monitor, a set-top box, an entertainment control unit (e.g., a gaming console), a digital camera, a portable music player, a digital video recorder, or a digital watch. In further implementations, the computing device **701** may be any other electronic device that processes data. In some implementations, the computing device **701**, IC package assembly **700**, and/or components thereof may be incorporated into an electronic device designed to be worn on the body of a human. In other implementations, the IC package assembly **700** or components thereof may be incorporated into a removable chip card.

EXAMPLES

Various embodiments of IC package assemblies with magnetic interconnect structures, methods for fabricating such IC package assemblies and magnetic interconnect structures, and systems incorporating IC substrates coupled by magnetic interconnect structures are described herein. In various

embodiments, an apparatus may comprise a first integrated circuit (IC) substrate having a first electrical routing feature and a first magnet coupled with the first electrical routing feature, a second integrated circuit (IC) substrate having a second electrical routing feature and a second magnet coupled with the second electrical routing feature, and an interconnect structure coupled with the first and second electrical routing features. In various embodiments, the interconnect structure may comprise a plurality of magnetic particles, and the first magnet and the second magnet may be configured to generate a magnetic field between the first magnet and the second magnet. In various embodiments, the magnetic particles may be electrically conductive and disposed in the magnetic field. In various embodiments, the magnetic particles may be movably coupled together, and the interconnect structure may be pliable. In various embodiments, the magnetic particles may have an electrically conductive outer portion and a magnetic interior portion. In various embodiments, the first magnet may be embedded in the first integrated circuit substrate.

In various embodiments, the first magnet may be disposed within the first electrical routing feature. In various embodiments, the first electrical routing feature may comprise a first pillar having a base portion adjacent to the first IC substrate and a top portion distal to the first IC substrate, and the second electrical routing feature may comprise a second pillar having a base portion adjacent to the second IC substrate and a top portion distal to the second IC substrate. In various embodiments, the first magnet may be disposed within the base portion of the first pillar, and the second magnet may be disposed within the base portion of the second pillar. In various embodiments, the first magnet may be disposed within the top portion of the first pillar, and the second magnet may be disposed within the top portion of the second pillar. In various embodiments, the first magnet may extend in a first lengthwise dimension from the base portion of the first pillar to the top portion of the first pillar, the second magnet may extend in a second lengthwise dimension from the base portion of the second pillar to the top portion of the second pillar, the first lengthwise dimension may be a largest dimension of the first magnet, and the second lengthwise dimension may be a largest dimension of the second magnet. In various embodiments, the first IC substrate may have a third electrical routing feature comprising a third pillar, a third magnet in the third pillar, and a fourth magnet disposed in the first IC substrate, and the fourth magnet may be magnetically coupled with the first magnet and the third magnet.

In various embodiments, the first integrated circuit substrate may include a die. In various embodiments, the second integrated circuit substrate may include another die, an interposer, or a package substrate. In various embodiments, the apparatus may further comprise a spacer disposed between the first and second integrated circuit substrates, and the spacer may be configured to maintain a minimum distance between the first and second integrated circuit substrates. In various embodiments, the first and second electrical routing features may be spaced apart by a gap, and the plurality of magnetic particles may form a conductive bridge across the gap from the first electrical routing feature to the second electrical routing feature. In various embodiments, the gap may have a height and the magnetic particles may have an average diameter in the range of 0.1% to 10% of the height of the gap. In various embodiments, the apparatus may comprise a fluid disposed between the first and second integrated circuit substrates, and the fluid may at least partially surround the interconnect structure. In various embodiments, the magnetic particles may have an electrically conductive outer portion

and a magnetic interior portion. In various embodiments, the first electrical routing feature may include a plurality of first electrical routing features, the first magnet may include a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and the first magnets may be arranged to form a checkerboard pole orientation pattern. In various embodiments, the first electrical routing feature may include a plurality of first electrical routing features, the first magnet may include a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and the first magnets may be arranged to form an alternating row pole orientation pattern.

In various embodiments, a method may comprise generating a magnetic field between a first electrical routing feature of a first integrated circuit substrate and a second electrical routing feature of a second integrated circuit substrate, wherein the magnetic field extends across a gap between the first and second electrical routing features, and forming an interconnect structure between the first and second electrical routing features. In various embodiments, generating the magnetic field may include magnetizing the first and second electrical routing features. In various embodiments, the interconnect structure may comprise a plurality of conductive magnetic particles. In various embodiments, one or more of the first integrated circuit substrate and the second integrated circuit substrate may include a die. In various embodiments, generating the magnetic field may include embedding a first magnet into the first electrical routing feature or the first integrated circuit substrate and embedding a second magnet into the second electrical routing feature or the second integrated circuit substrate. In various embodiments, generating the magnetic field may include positioning the first and second electrical routing features in substantial axial alignment such that corresponding first and second magnetic fields of the first and second electrical routing features overlap along said gap. In various embodiments, forming the interconnect structure between the first and second electrical routing features may include applying the plurality of conductive magnetic particles to one or more of the first and second integrated circuit substrates. In various embodiments, forming the interconnect structure between the first and second electrical routing features may include dispensing the plurality of conductive magnetic particles into a gap between the first and second integrated circuit substrates.

In various embodiments, a method may comprise reducing a magnetic field between a first electrical routing feature of a first integrated circuit substrate and a second electrical routing feature of a second integrated circuit substrate, and separating the first integrated circuit substrate from the second integrated circuit substrate. In various embodiments, a plurality of conductive magnetic particles may be disposed in a gap between the first and second electrical routing features, and reducing the magnetic field may reduce a magnetic attraction between the conductive magnetic particles and the first and second electrical routing features.

In various embodiments, the first and second integrated circuit substrates may include one or more magnets coupled with the first and second electrical routing features, and reducing the magnetic field may include heating the one or more magnets to a Curie temperature of the one or more magnets. In various embodiments, the first and second integrated circuit substrates may include one or more magnets coupled with the first and second electrical routing features, and reducing the magnetic field may include heating the one or more magnets to a partial demagnetization temperature (PDT) of the one or more magnets. In various embodiments, the first and second integrated circuit substrates may include

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one or more magnets coupled with the first and second electrical routing features, and reducing the magnetic field may include heating the conductive magnetic particles to a Curie temperature of the one or more magnets. In various embodiments, the first and second integrated circuit substrates may include one or more magnets coupled with the first and second electrical routing features, and reducing the magnetic field may include heating the conductive magnetic particles to a partial demagnetization temperature (PDT) of the one or more magnets. In various embodiments, the method may further include coupling the first electrical routing feature of the first integrated circuit substrate with a third electrical routing feature of a third integrated circuit substrate after separating the first integrated circuit substrate from the second integrated circuit substrate. In various embodiments, one or more of the first integrated circuit substrate and the second integrated circuit substrate may include a die.

In various embodiments, a system may comprise a circuit board and a package assembly coupled with the circuit board, and the package assembly may include a first integrated circuit substrate having a first electrical routing feature and a first magnet coupled with the first electrical routing feature, a second integrated circuit substrate having a second electrical routing feature and a second magnet coupled with the second electrical routing feature, and an interconnect structure coupled with the first and second electrical routing features, and the interconnect structure may comprise a plurality of magnetic particles. In various embodiments, the magnetic particles may be electrically conductive. In various embodiments, the magnetic particles may be movably coupled together and the interconnect structure may be pliable. In various embodiments, one or more of the integrated circuit substrates may include a die. In various embodiments, the system may be embodied in an electronic device configured to be worn on a body. In various embodiments, the first electrical routing feature may include a plurality of first electrical routing features, the first magnet may include a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and the first magnets may be arranged to form a checkerboard pole orientation pattern. In various embodiments, the first electrical routing feature may include a plurality of first electrical routing features, the first magnet may include a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and the first magnets may be arranged to form an alternating row pole orientation pattern.

Various embodiments may include any suitable combination of the above-described embodiments. Furthermore, some embodiments may include one or more non-transitory computer-readable media having instructions, stored thereon, that when executed result in actions of any of the above-described embodiments. Moreover, some embodiments may include apparatuses or systems having any suitable means for carrying out the various operations of the above-described embodiments.

The above description of illustrated implementations, including what is described in the Abstract, is not intended to be exhaustive or to limit the embodiments of the present disclosure to the precise forms disclosed. While specific implementations and examples are described herein for illustrative purposes, various equivalent modifications are possible within the scope of the present disclosure, as those skilled in the relevant art will recognize.

These modifications may be made to embodiments of the present disclosure in light of the above detailed description. The terms used in the following claims should not be construed to limit various embodiments of the present disclosure

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to the specific implementations disclosed in the specification and the claims. Rather, the scope is to be determined entirely by the following claims, which are to be construed in accordance with established doctrines of claim interpretation.

What is claimed is:

1. An apparatus comprising:

a first integrated circuit (IC) substrate having a first electrical routing feature and a first magnet coupled with the first electrical routing feature, wherein the first magnet is disposed within the first electrical routing feature;

a second integrated circuit (IC); and

an interconnect structure coupled with the first electrical routing feature, the interconnect structure comprising a plurality of magnetic particles.

2. The apparatus of claim 1, wherein the second IC substrate includes a second electrical routing feature and a second magnet coupled with the second electrical routing feature.

3. The apparatus of claim 2, wherein the first magnet and the second magnet are to generate a magnetic field between the first magnet and the second magnet and wherein the magnetic particles are electrically conductive and disposed in the magnetic field.

4. The apparatus of claim 2, wherein:

the first electrical routing feature includes a first pillar with a base portion adjacent to the first IC substrate and a top portion distal to the first IC substrate; and

the second electrical routing feature includes a second pillar with a base portion adjacent to the second IC substrate and a top portion distal to the second IC substrate.

5. The apparatus of claim 2, wherein the first and second electrical routing features are spaced apart by a gap, and the plurality of magnetic particles forms a conductive bridge across the gap from the first electrical routing feature to the second electrical routing feature.

6. The apparatus of claim 1, wherein the magnetic particles are movably coupled together and the interconnect structure is pliable.

7. The apparatus of claim 1, wherein the magnetic particles have an electrically conductive outer portion and a magnetic interior portion.

8. The apparatus of claim 1, wherein the first IC substrate is a die.

9. The apparatus of claim 1, further comprising a spacer disposed between the first and second IC substrates, wherein the spacer is to maintain a minimum distance between the first and second IC substrates.

10. The apparatus of claim 1, wherein the first electrical routing feature includes a plurality of first electrical routing features, and the first magnet includes a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and wherein the first magnets are arranged to form a checkerboard pole orientation pattern.

11. The apparatus of claim 1, wherein the first electrical routing feature includes a plurality of first electrical routing features, and the first magnet includes a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and wherein the first magnets are arranged to form an alternating row pole orientation pattern.

12. A system comprising:

a circuit board; and

a package assembly coupled with the circuit board, wherein the package assembly includes

a first integrated circuit (IC) substrate having a first electrical routing feature and a first magnet coupled

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with the first electrical routing feature, wherein the first magnet is disposed within the first electrical routing feature;

a second integrated circuit (IC) substrate; and
an interconnect structure coupled with the first electrical routing feature, the interconnect structure comprising a plurality of magnetic particles.

13. The system of claim 12, wherein the magnetic particles are movably coupled together and the interconnect structure is pliable.

14. The system of claim 12, wherein the second IC substrate includes a second electrical routing feature and a second magnet coupled with the second electrical routing feature.

15. The system of claim 14, wherein the first magnet and the second magnet are to generate a magnetic field between the first magnet and the second magnet and wherein the magnetic particles are electrically conductive and disposed in the magnetic field.

16. The system of claim 12, wherein the first electrical routing feature includes a plurality of first electrical routing features, and the first magnet includes a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, and wherein the first magnets are arranged to form a checkerboard pole orientation pattern.

17. The system of claim 12, wherein the first electrical routing feature includes a plurality of first electrical routing features, and the first magnet includes a plurality of first magnets coupled with corresponding ones of the plurality of

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first electrical routing features, and wherein the first magnets are arranged to form an alternating row pole orientation pattern.

18. An apparatus comprising:

a first integrated circuit (IC) substrate with a plurality of first electrical routing features and a plurality of first magnets coupled with corresponding ones of the plurality of first electrical routing features, wherein the first magnets are arranged to form a checkerboard pole orientation pattern or an alternating row pole orientation pattern;

a second integrated circuit (IC) substrate; and
interconnect structures coupled with the plurality of first electrical routing features, the interconnect structures with a plurality of magnetic particles.

19. The apparatus of claim 18, wherein the magnetic particles have an electrically conductive outer portion and a magnetic interior portion.

20. The apparatus of claim 18, wherein the second IC substrate includes a plurality of second electrical routing features and a plurality of second magnets coupled with corresponding ones of the plurality of second electrical routing features.

21. The apparatus of claim 20, wherein the first magnets and the second magnets are to generate a magnetic field between the first magnets and the second magnets, wherein the magnetic particles are electrically conductive and disposed in the magnetic field.

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